

Interacting with DARPA

Brian Holloway
DARPA Program Manager
Defense Science Office
Brian.holloway@darpa.mil

American Vacuum Society Meeting

October 31, 2011





What makes DARPA unique...

Formed in 1958 to
PREVENT and **CREATE** strategic surprise

Capabilities, mission focused

Finite duration projects

Diverse performers

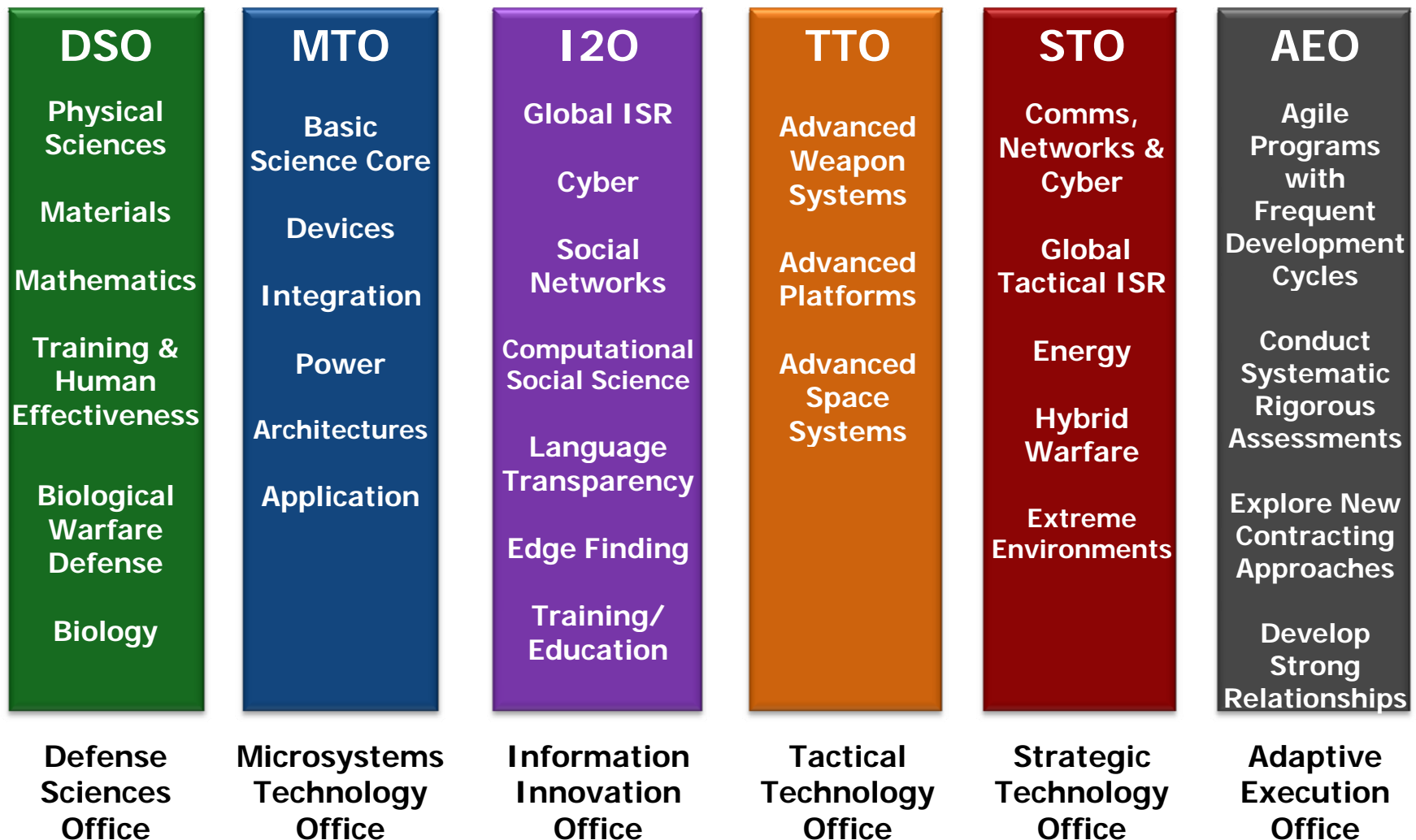
Multi-disciplinary approach...from
basic research to system engineering

As the DoD's innovation engine, we
are committed to the boldest, creative leaps...



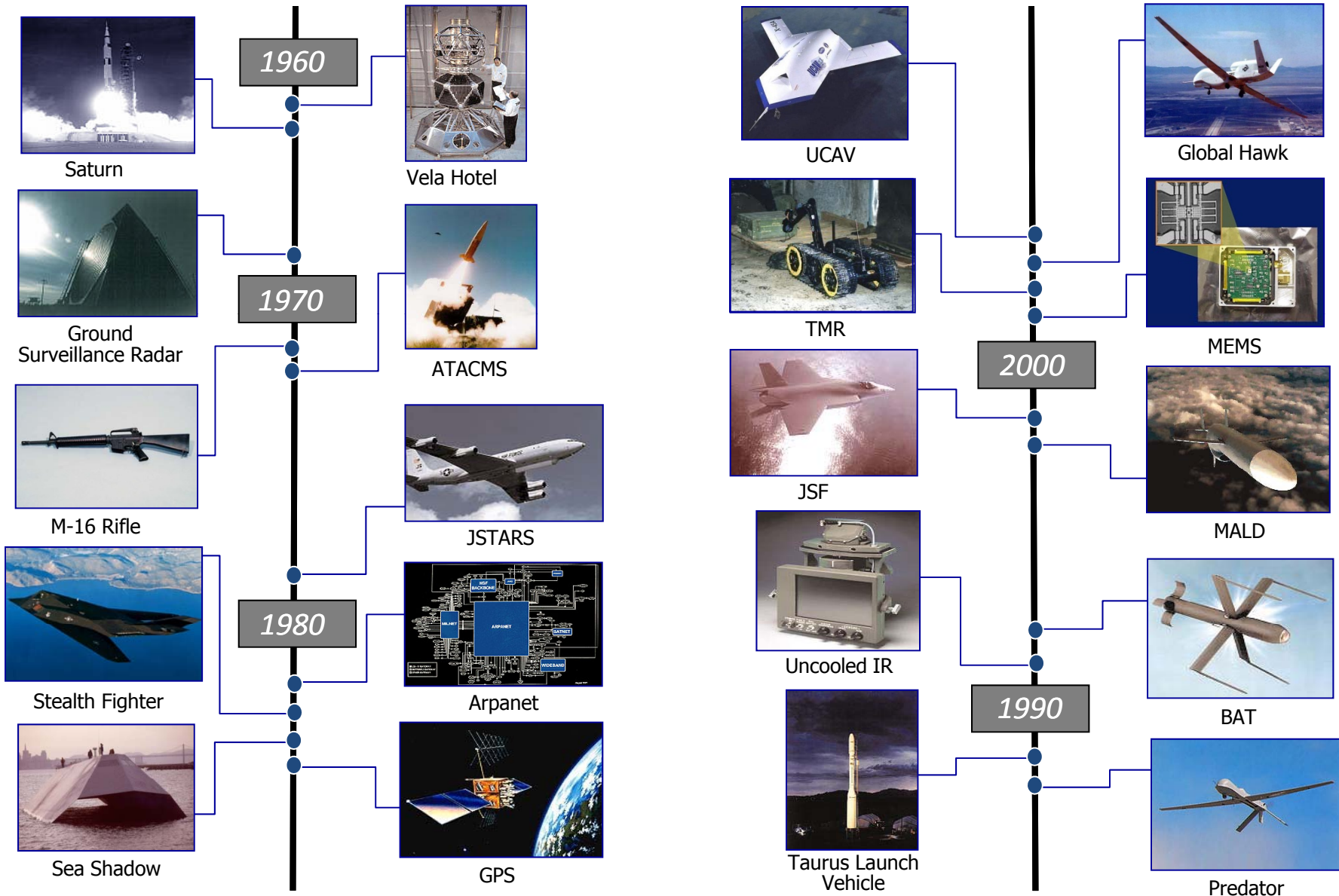


DARPA Structure





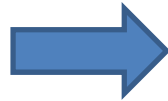
DARPA Accomplishments Timeline





Working with DARPA

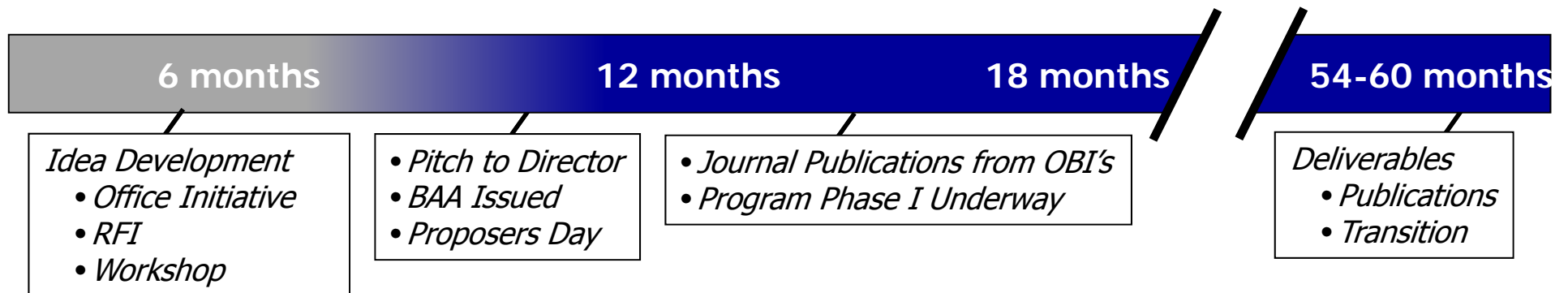
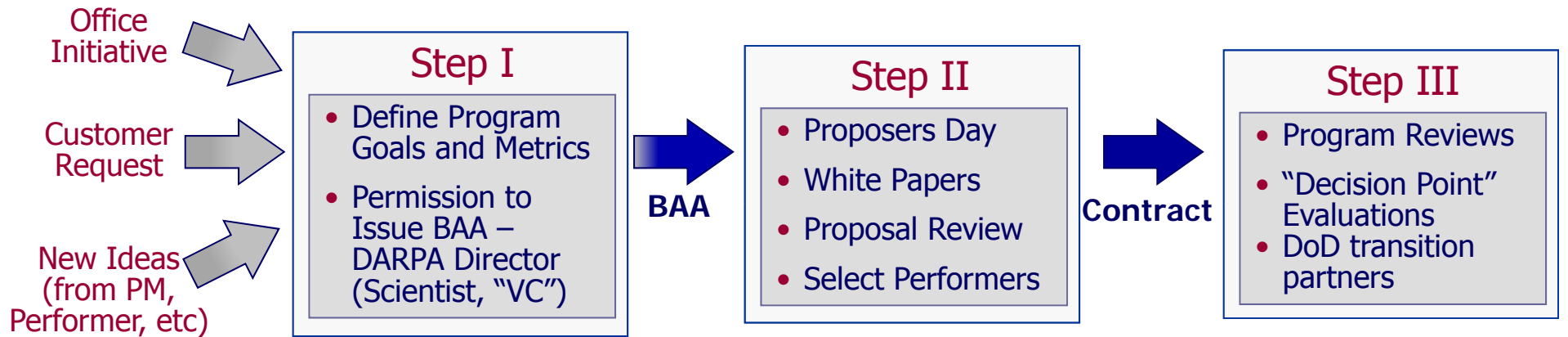
Potential Performers
Industry, Universities,
National Labs



Program Manager
Scientist
Entrepreneur
"Angel Investor"



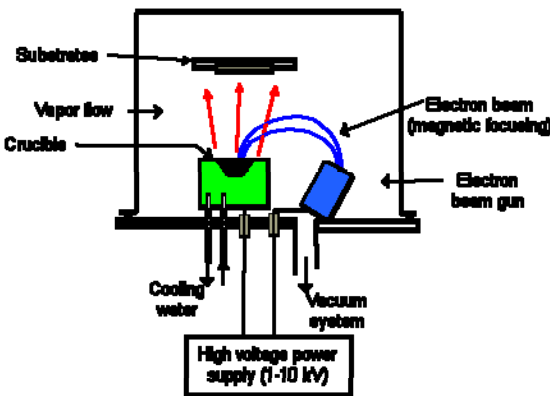
Office Initiatives
(Proof of Concept)





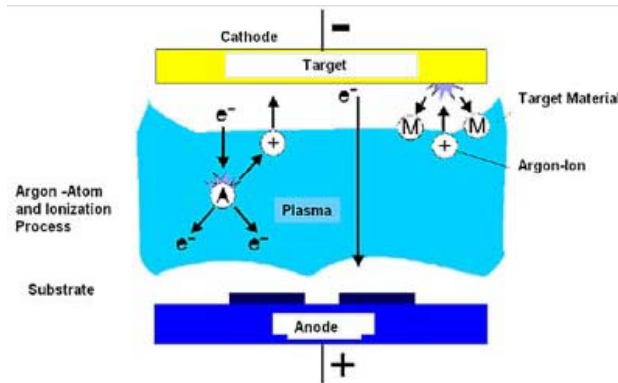
Present day thin film growth processes

- Evaporation (thermal, electron beam).
- Sputtering (inert, reactive gas).
- Molecular beam epitaxy, laser ablation.
- Chemical vapor deposition (CVD), plasma-enhanced CVD.



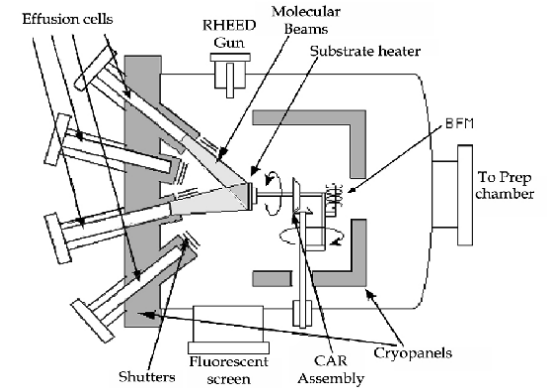
Electron beam evaporation

www.etafilm.com.tw/PVD_Thermal_Evaporation_Deposition.html



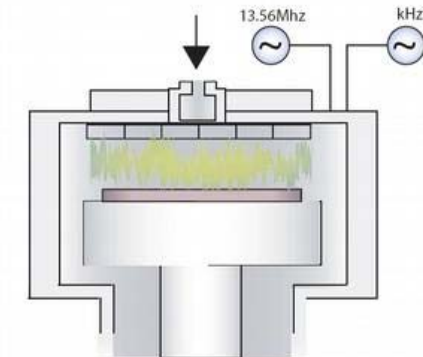
Sputtering

www.svs-vct.com/sputtering.htm



Molecular beam epitaxy

mxp.physics.umn.edu/s07/Projects/S07_Graphene/intro.htm



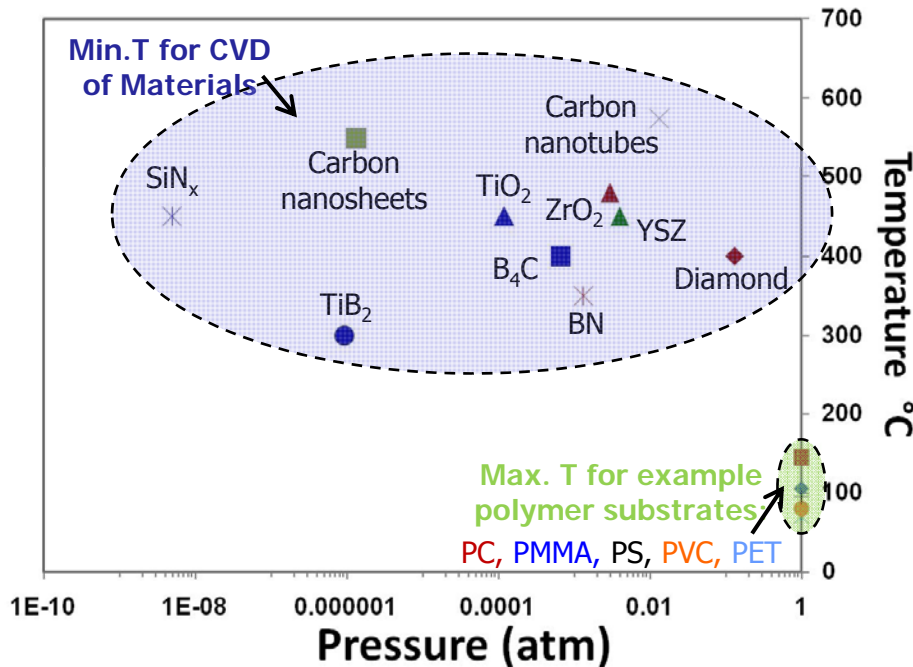
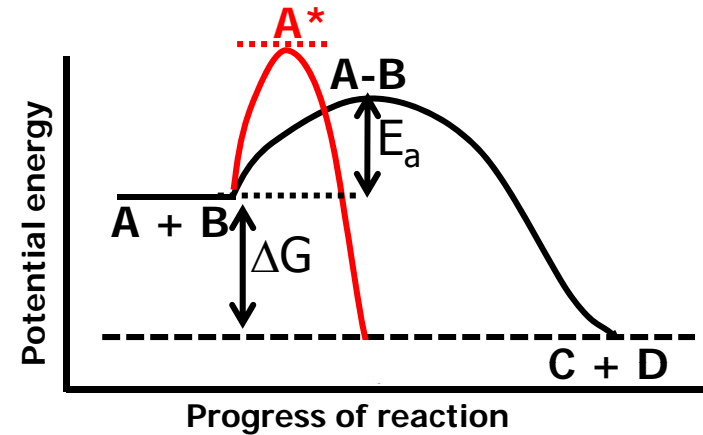
Plasma-enhanced chemical vapor deposition

unit.aist.go.jp/dia-rc/dia-surf/SFD-project-diamond%20growth.html



Current thin film deposition processes

- Proceed via equilibrium macroscopic chemistry and kinetics.
- Driven by ΔG and E_a .
- Extreme bulk temperature and vacuum conditions severely limits the combination of technologically important materials with relevant substrates.



The gap is an engineering limitation, not a fundamental scientific limitation.



Possible tools for Local Control (LoCo)

Atmospheric Pressure Plasmas (APP): high flux of energetic reactants to surface.

Types of APPs

- Corona discharges
- High frequency glow discharges:
- Dielectric barrier discharges

Recent Advances

- Power supply power, matching networks, pulse quality
- Understanding of plasma chemistry and physics



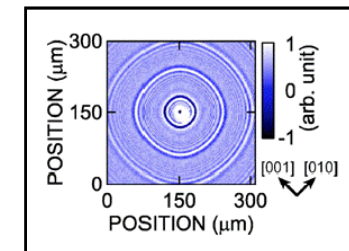
Surface Acoustic Waves (SAW): local energy for surface diffusion without heating.

Example T equivalent calculation

- Pulsed lasers used to induce propagating Rayleigh waves.
- Strain induced by SAWs shown to be on order of that that affects surface adsorbates and dislocations.

Recent Advances

- Development of SAW spectroscopy, with the ability to manipulate and control SAWs (picosecond temporal and micron lateral resolution)
- Buried interface perturbation



Ultrafast Lasers (UL): chemical specificity for bond scission/formation (reactants and substrate).

Critical control properties

- Pulse width
- Photon frequency
- Pulse shape
- Phase

Recent Advances

- Pulse shape, frequency control, and phase optimization for improved selectivity in bond scission and formation
- Higher power, higher frequency lasers

